

EAST Search History

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
S1	889	underlayer same photoresist	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/04/25 06:44
S2	1	underlayer near3 porous same photoresist	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/04/11 07:11
S3	1	underlayer same photoresist and blowing near agent same solvent same organic	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/04/11 07:12
S4	1	underlayer same photoresist and polymer and (diazoacetamide azonitrile benzenesulfohydrazine azocarboxylic)	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/04/11 07:34
S5	1	underlayer same photoresist and polymer and (azodicarbonamide barium near azodicarboxylate)	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/04/11 07:24
S6	1	underlayer same photoresist and polymer and azocarboxylic	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/04/11 07:24
S7	2	(antireflective arc) and photoresist and polymer and (diazoacetamide azonitrile benzenesulfohydrazine azocarboxylic)	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/04/11 07:26
S8	2	"2002207295"	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/04/11 07:26

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S9	0	(resist photoresist) near2 lower and polymer and (diazacetamide azonitrile benzenesulfohydrazine azocarboxylic)	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/04/11 07:35
S10	0	(resist photoresist) near3 lower and polymer and (diazacetamide azonitrile benzenesulfohydrazine azocarboxylic)	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/04/11 07:35
S11	1	(resist photoresist) near3 underlayer and polymer and (diazacetamide azonitrile benzenesulfohydrazine azocarboxylic)	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/04/11 09:01
S12	35	(resist photoresist) and polymer and (diazacetamide azonitrile benzenesulfohydrazine azocarboxylic)	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/04/17 09:08
S13	2	((("6791649") or ("20020018886")). PN.	US-PGPUB; USPAT; USOCR	OR	OFF	2007/04/11 09:29
S14	35	(resist photoresist) and polymer and (diazacetamide azonitrile benzenesulfohydrazine azocarboxylic)	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/04/17 09:09
S15	39	(resist photoresist) and (diazacetamide azonitrile benzenesulfohydrazine azocarboxylic)	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/04/17 09:13
S16	4	S15 not S14	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/04/17 09:09
S17	1174	(resist photoresist) and blowing near agent	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/04/17 09:23

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S18	46	S17 and semiconductor	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/04/17 09:14
S19	45	S18 not (S14 S15)	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/04/17 09:14
S20	1131	(resist photoresist) and (azodicarbonamide barium near azodicarboxylate azobis near isobutyronitrile dinitrosopentamethylene near tetramine oxybis near benzenefulfonyl near hydrazide azobis near2 cyanovaleric azobis near cyclohexanecarbonitrile azobis near3 dimethylformamide azodicarbonyl near dipiperidine dephenyltriazene nitrosoresorcine near monomethyl near ether)	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/04/17 09:26
S21	250	S20 and semiconductor	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/04/17 09:27
S22	240	S21 not (S14 S15 S18)	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2007/04/17 09:27
S23	7	((("20030207208") or ("20020172896") or ("5028661") or ("6803168") or ("20030087179") or ("20030019192") or ("20030186160")).PN.	US-PGPUB; USPAT; USOCR	OR	OFF	2007/04/25 06:46
S24	7	((("20030207208") or ("20020172896") or ("5028661") or ("6803168") or ("20030087179") or ("20060019192") or ("20030186160")).PN.	US-PGPUB; USPAT; USOCR	OR	OFF	2007/04/25 06:46